Spatially resolved electronic structure of an isovalent nitrogen center in GaAs

R. C. Plantenga,1 V. R. Kortan,2 T. Kaizu,3 Y. Harada,3 T. Kita,3 M. E. Flatté,1,2 and P. M. Koenraad1

1Department of Applied Physics, Eindhoven University of Technology, P.O. Box 513, 5600 MB Eindhoven, The Netherlands
2Department of Physics and Astronomy, University of Iowa, Iowa City, Iowa 52242, USA
3Department of Electrical and Electronic Engineering, Graduate School of Engineering, Kobe University, 1-1 Rokkodai, Nada, Kobe 657-8501, Japan

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Small numbers of nitrogen dopants dramatically modify the electronic properties of GaAs, generating spatially localized resonant states within the conduction band, pair and cluster states in the band gap, and very large shifts in the conduction-band energies with nonlinear concentration dependence. Cross-sectional scanning tunneling microscopy provides the local electronic structure of single nitrogen dopants at the (110) GaAs surface, yielding highly anisotropic spatial shapes when the empty states are imaged. Measurements of the resonant states relative to the GaAs surface states and their spatial extent allow an unambiguous assignment of specific features to nitrogen atoms at different depths below the cleaved (110) surface. Multiband tight-binding calculations around the resonance energy of nitrogen in the conduction band match the imaged features, verifying that the Green’s function method can accurately describe the isolated isovalent nitrogen impurity. The spatial anisotropy is attributed to the tetrahedral symmetry of the bulk lattice and will lead to a directional dependence for the interaction of nitrogen atoms. Additionally, the voltage dependence of the electronic contrast for two features in the filled state imaging suggests these features could be related to a locally modified surface state.

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I. INTRODUCTION

In GaAs, the addition of small amounts of nitrogen can have a strong effect on the electronic properties. At concentrations well below 1% (i.e., <10¹⁹ cm⁻³), nitrogen induces a localized state which gives a strong narrow line in optical measurements, corresponding to an energetic feature 150–180 meV above the conduction-band edge [1–5]. Thus, unlike for nitrogen in GaP, the resonance level of a single nitrogen lies in the conduction band of GaAs. Additional narrow lines have been found in the photoluminescence spectra, and assigned to other states involving the single nitrogen, N-N pairs, and N clusters, several of which are situated in the band gap [6–21].

From the rich spectra [3], the appearance of the lines with different growth configurations [10,13] and dependence of the signal on polarization and magnetic field [17,18,20] it was suspected that nitrogen pairs give rise to different electronic levels depending on the relative orientation of their two constituents. The resonant states thus obtained are not only interesting as single-photon sources with many available energies. Resonant states have also gained interest as probes of localized centers by transport measurements as demonstrated, for example, in Refs. [22–24]. The study of dopant complexes plays a major role in quantum spintronics as well, as studies of states beyond the NV center in diamond, or the divacancy center in silicon carbide, would benefit from these types of studies.

Further alteration of the electronic structure of GaAs can be seen for nitrogen at low alloying concentrations (typically 0.1%–2.0%) at which the band gap of GaAsN is reduced up to 600 meV below that of GaAs [25–27] despite the band gap of GaN exceeding that of GaAs by a factor of 2. Strong band bowing, common for highly mismatched alloys, has been attributed to the hybridization of the localized nitrogen states with the GaAs conduction band [28,29] or the formation of a continuum of localized states forming an impurity band [6,30,31].

Multiple theoretical approaches have produced estimates of the energy levels of the single N impurity, N-N pairs, and N clusters [6,28–43], including tight-binding calculations, empirical pseudopotential calculations, band anticrossing models, and density functional theory. The band anticrossing model [28,29] is very successful in explaining the observed trend for band-gap narrowing at low nitrogen content, but is a quasiperiodic theory and thus does not address the spatial structure of individual nitrogen dopants. Several supercell calculations were performed [35–38,40–42], of which Ref. [42] is the most extensive, including the energy of the single N level and N-N pair levels, the band gap over the full nitrogen concentration range, and a prediction for the spatial extent of the wave function. A strong directional dependence of the N-pair levels was found here as well. However, even though the supercells are almost 7 nm in linear size, significant finite-size effects have been found even for these sizes for well-hybridized states close to the conduction band or resonances within the conduction band [44].

Additionally, ab initio atomistic calculations, like density functional theory calculations, are unable to derive the long-ranged electronic structure that follows from the mixing with the bulk dispersion, as the dispersion relation is not accurately represented. Tight-binding calculations with open boundary conditions, based on the Koster-Slater formalism in terms of Green’s functions, do take the dispersion relation into account and are not influenced by boundary effects found in supercell calculations. Although similar calculations have been performed for the single nitrogen impurity in GaAs [43], no spatial structure was derived and no verification of this spatial structure with experiments was done.

Here, we use cross-sectional scanning tunneling microscopy (X-STM) to directly image the local density of states (LDOS) related to the resonant level of the individual nitrogen in the conduction band. X-STM has been applied successfully in the past to image nitrogen atoms in GaAs as atomically
sized features and determine the distribution of nitrogen in various structures such as quantum wells [45–49]. However, until recently little attention has focused on the imaging of the electronic state of nitrogen [50].

By giving a full description of the appearance of the single nitrogen impurity, we aim not only to develop a robust way of identifying nitrogen features in more complex systems, but we want to obtain better understanding of the origin of the directional dependence of nitrogen pairing states. Furthermore, we want to use the STM as a method to verify that the Green’s function tight-binding method can give a high-quality description of the single nitrogen and as such can be applied to calculations as have been presented, for example, in Ref. [43] on band bowing. In those calculations, a linear combination of isolated nitrogen states (LCINS) is made to make an estimate of the spectral distribution of the nitrogen band. Indeed, our results here show there is a good match between the experimentally observed and calculated appearance of the single nitrogen and hence confirm that tight-binding calculations following the Green’s function formalism for the single nitrogen provide a good basis for the LCINS.

II. METHOD

The sample was grown at 550 °C by MBE using a 1.1 × 10^18 cm⁻³ n⁻⁺-doped GaAs wafer as the substrate and nitrogen from a radio-frequency plasma source with ultrapure N₂ gas [17,19]. After a 400 nm buffer layer of 1.0 × 10^18 cm⁻³ n⁻⁺-doped GaAs, 3 nm Al₀.₃Ga₀.₇As marker layers and N layers were alternately grown, starting and ending with an Al₀.₃Ga₀.₇As layer, with GaAs spacer layers in between of at least 35 nm. N layers were deposited by stopping the Ga flux and opening the N flux for 2000 s. During the nitridation, the As₂ flux was kept at the same flux as during the growth (1.0 × 10⁻⁶ Torr). Growth was recommenced 120 s after stopping the N flux. After the last marker layer, a 250 nm GaAs capping layer was grown. The nitridation was monitored by reflection high-energy electron diffraction.

The X-STM measurements were performed bringing the sample in ultrahigh vacuum (UHV, pressure typically around 5 × 10⁻¹¹ Torr) and cleaving the sample there, revealing a (110) plane. The sample was then cooled to 77 K. STM tips were made from electrochemically etching a tungsten wire, which was then further sharpened and cleaned by argon sputtering in vacuum. Sample bias was varied per experiment, while currents were kept between 10–50 pA. Images were taken in constant current mode. Illumination of the sample was used to create charge carriers in the regions between the AlGaAs barriers.

III. RESULTS AND DISCUSSION

The position of the nitrogen layer is easily traceable with the help of the AlGaAs marker layers. The marker layers are not shown in the images here since they are located 40 nm or further away. The nitrogen layer was imaged at various sample bias voltages (see Fig. 1). At negative sample bias, dark spotlike features and two types of features containing bright contrast (indicated B1 and B2) can be observed [see Fig. 1(a)]. Dark contrast features have been observed for nitrogen in X-STM in the past with filled state imaging [45–48] and have been reproduced in theoretical models [51,52]. The observation of dark contrast is attributed to a depression at the surface caused by the shortened bonds between the nitrogen and its neighboring Ga atoms. These dark spots show a variation in intensity due to the variation in depth at which the nitrogen atoms are positioned with respect to the surface. The nitrogen atoms located deeper below the surface give rise to less distortion at the surface and thus a weaker dark contrast.

The features B1 and B2 always occur around the nitrogen layer. Therefore, we propose that these must be nitrogen related as well. Both features show a periodic pattern along the [110] direction, forming barlike contrast in the [001] direction. The extent of both features differs, with the B1 feature extending about three rows in two directions and the B2 extending at least five rows in both directions. In previous X-STM measurements at room temperature [45–48] these features were not observed. A recent publication on X-STM measurements at 77 K reports a feature similar to B1 and B2, although the structure of the features was less clearly resolved [50]. Discussion of both B1 and B2 will be continued later.

When imaging at +0.60 V sample bias [see Fig. 1(b)], various types of bright features can be distinguished having a complex structure with a strong anisotropy between the [110] and [001] directions. At positive sample bias, these features
are located at the exact positions of the dark and bright features seen at $-1.90\,\text{V}$. Similar features have been observed by Ishida et al.\,[50]. As will be discussed later, these features are related to nitrogen substituting for arsenic atoms in different planes below the surface, where the labels 0 to 4 indicate the distance from the (110) cleavage surface in number of planes. Unlike the dark features at $-1.90\,\text{V}$, all of these bright features are caused by increased tunneling current due to an enhanced local density of states (LDOS) at a resonance energy rather than the topography.

At a higher voltage of $+1.00\,\text{V}$ [see Fig. 1(c)], the 0 feature develops a strong contrast directed along the [110] direction. The structure of the other features becomes more condensed while the anisotropy in the [001] direction is preserved. At $+1.40\,\text{V}$ [see Fig. 1(d)], the only bright contrast is observed at the 0 feature. The other features with bright contrast at lower positive voltages now show a strong dark contrast, that unlike the localized features at negative voltage spread over multiple atomic positions. At $+1.40\,\text{V}$, the observed image deviates strongly from the observed topography at negative voltages and hence the dark contrast is attributed to an electronic origin.

A reduction of LDOS to compensate for the enhancement of the LDOS at the nitrogen resonance energy is suspected. The nitrogen is an isoelectronic impurity and therefore does not introduce additional density of states when considering the integral over all energies and space. Hence, a local increase of LDOS at a specific energy has to be compensated elsewhere in space and energy.

Comparing the measurements at positive voltages, we see that the contrast intensity of the features varies with the applied sample bias. A different voltage dependence is seen per plane the nitrogen is situated in; the features related to the surface (0) hardly show any contrast at $+0.60\,\text{V}$ [Fig. 1(b)], while for the fourth layer features (4) a clear contrast can be seen. At $+1.00\,\text{V}$ [Fig. 1(c)], this is reversed. To quantify this behavior the highest contrast associated with this feature, normalized to the atomic corrugation found on clean GaAs observed at the same voltage, was determined for each feature for at least seven voltages in the range $+0.40$ to $+1.60\,\text{V}$ (see Supplemental Material S1\,[53] and inset Fig. 2). For every depth of the nitrogen below the surface, including the surface nitrogen, a resonance in the voltage-dependent contrast intensity is found. Ishida et al. also suggested that a trend of resonance voltage with depth could be present as they saw a shift in the differential tunneling conductance spectra when comparing the fourth and seventh layer features\,[50]. A Voigt profile is used to get an estimate of the voltage at which the resonance occurs (see Supplemental Material S1\,[53]). In Fig. 2, the estimated resonance is plotted against the layer in which the nitrogen resides. A large jump in resonance voltage can be seen when going from the surface nitrogen to the first layer nitrogen, while a more gradual drop is observed for deeper lying nitrogen. It is important to realize that the energy position of the resonances will be influenced by tip-induced band bending (TIBB). The electric field following the voltage on the tip pulls up the GaAs bands as well as the nitrogen resonance. The TIBB is strongest at the surface and decays away from the surface, hence, features close to the surface align with the Fermi energy of the tip at higher voltages than features farther away from the surface. We propose that the observed trend seen for the features below the surface is mostly from TIBB, although energy shifts due to deviations from the distortions around an impurity close to the surface with respect to the bulk lattice can not be fully excluded. However, the jump we see for the surface nitrogen is most likely not mainly as a result of the TIBB.

We expect that the surface state has a significantly different energy caused by the strongly modified atomic coordination environment at the surface\,[54].

Our resonant voltages differ in absolute value with the STS results of Ishida et al. and Ivanova et al. In Refs.\,[49,50] the peak position of the single nitrogen level in general shows up between $+1.2$ and $+1.7\,\text{V}$. As illustrated well by the spectroscopy series of Ishida et al., the observed values in STS are dependent on the tip condition, hence, we are reluctant to compare the exact values resulting from STS. The difference observed with our value is most probably due to the use of illumination and a more intrinsic environment in our case. Illumination creates charge carriers, partially quenching the TIBB\,[55], while the doping influences the positioning of the Fermi level.

Ishida et al. do not find a defined peak in their spectrum for the resonance of the nitrogen in the surface position, while Ivanova et al. indicate that they do not expect a contribution of the surface nitrogen state at all in STS. The resonance that we found with constant current imaging at various voltages for nitrogen in the surface layer (see inset Fig. 2) shows a peak that is broader than found for most nitrogen in other layers. Together with the observation that the resonance of the surface nitrogen lies 0.5 V above the next resonance, this could be an indication why no peak was observed in earlier STS measurements; either the peak is smeared out too much, and thus not showing up clearly on top of the regular LDOS, or the peak position is shifted up outside the measured region, or a combination of both.

In order to identify the position of the nitrogen atoms in the lattice, it is necessary to determine their position with...
FIG. 3. (a) Five nitrogen-related features found at $+0.75\, \text{V}$ (upper) sample bias, organized by extent in the [001] direction, and their counterparts at $-1.90\, \text{V}$ (lower). The contrast for the third layer feature at $-1.90\, \text{V}$ was adjusted to span 17 pm more (the corrugation at $-1.90\, \text{V}$ spans $\sim 10\, \text{pm}$) to see the finer structure of the bright contrast. The cross hairs indicate the position of the feature’s center with respect to the surface resonances. Note that a second nitrogen feature is present in the panel depicting the first layer feature at $-1.90\, \text{V}$. Only the centered feature is associated with the first layer. (b) Slice of the surface scanned in the X-STM along a (110) plane, showing in side view the positions a nitrogen atom can take when substituting for the arsenic atom. (c) View from the top onto the surface scanned in X-STM, and the two possible in-plane positions for the nitrogen on substitutional sites indicated with a blue dot with dashed circle. The stronger lines and bigger atoms indicate the elevated zigzag rows in the surface. (d), (e) Show the relative position of these projections to the surface resonances imaged at negative and positive voltage, respectively.

respect to the gallium and arsenic atoms on the surface. As can be seen from Fig. 1, the corrugation on the undoped GaAs surface depends on the applied sample bias. At $-1.90$ and $+1.00\, \text{V}$, a two-dimensional (2D) atomic grid can be observed, whereas at $+0.60\, \text{V}$ stripes directed along [110] are seen and at $+1.40\, \text{V}$ stripes directed along [001] are seen. The observed stripes are attributed to surface states that arise after the surface relaxation and strongly correlate to the position of the surface atoms [56,57]. We follow labeling of Refs. [56,57] in which the various surface states that were calculated were labeled A or C, according to whether the state was mainly related to the anion (A) or cation (C) sites. The maximum contribution of each of these surface states lies at a different energy, from which the numbering is derived. The spatial contribution of these states is schematically indicated in Fig. 3. Around the bottom of the conduction band the C3 state is found to be dominant, giving rise to stripes which are directed along [001] and centered on top of the dangling bonds of the surface gallium atoms. At low positive voltages we inject into the lower part of the conduction band the C3 state is found to be dominant, giving rise to stripes which are directed along [001] and centered on top of the dangling bonds of the surface gallium atoms. At low positive voltages we inject into the lower part of the conduction band via the C3 state, therefore, at $+0.60\, \text{V}$ stripes along [001] are observed. At high positive voltages, like $+1.40\, \text{V}$, we inject into the conduction band via the C4 surface resonance state, which is centered on the dangling bonds of gallium as well, but is now directed along [110]. Thus, we see a voltage-dependent corrugation. The measurement at $+1.00\, \text{V}$ shows a 2D grid for the corrugation because at this voltage the C3 and C4 states contribute with similar weight.

For the measurements at $-1.90\, \text{V}$, a 2D grid is observed as well. This is remarkable because at negative voltages electrons are drawn from the valence band, which lines up with the maxima of the A4 and A5 surface states. The A4 and A5 states are centered around the arsenic surface atoms and are both directed along [110]. As was reported by de Raad et al. [58], due to TIBB it is possible to observe contributions from the C3 mode also at negative voltages when tunneling close to the gap. Therefore, at $-1.90\, \text{V}$ a 2D grid is formed from the C3 state and the A5 state, whose maximum is located closer to the gap than that of the A4.

After taking into account the atomic corrugation for the clean GaAs surface, the nitrogen features can be classified according to their position below the (110) surface. In the image Fig. 1(b) and many other images, at least five different contrast varieties can be observed. Figure 3(a) shows these features at $+0.75\, \text{V}$.
the bright contrast in the [001] direction we see that their centers alternatingly fall on top or in-between the imaged atomic grid [see the top row in Fig. 3(a)]. At $-1.90 \text{ V}$, the feature centers show an alternation of position with the imaged grid as well [see the bottom row in Fig. 3(a)]. Their positions with respect to the surface state along [001] are the same as observed for the features at $+0.75 \text{ V}$. However, the features that are centered on top of the maxima of the surface state along [110] at $+0.75 \text{ V}$ fall in between the state directed along [110] at $-1.90 \text{ V}$ and vice versa.

The nitrogen atom normally substitutes for an arsenic atom. Nitrogen atoms positioned at even numbered layers [see Fig. 3(b)] will create a depression centered on the position of a surface arsenic atom [see Fig. 3(c)]. Hence, at $-1.90 \text{ V}$ the even numbered nitrogen atoms will show up on the A5 surface resonance in the [110] direction and between the C3 resonance in the [001] direction [see Fig. 3(d)]. Nitrogen atoms on the arsenic positions in the odd numbered layers [see Fig. 3(b)] are not directly imaged, but will cause a distortion distributed over multiple arsenic atoms with the center of the contrast in between the surface arsenic atoms, hence in between the stripes due to the A5 state. From Fig. 3(d) it can also be seen that these odd numbered features fall in line with the Ga atoms along [001] and therefore will be imaged on the C3 grid. We conclude that the states labeled with 0, 2, and 4 are indeed related to the even numbered substitutional sites and the features labeled 1 and 3 to the odd numbered substitutional sites shown in Fig. 3(b).

The images at $+0.75 \text{ V}$ have the same C3 surface state making up the rows along [001]. The center of the features hence have a similar position with respect to the [001] rows. The C4 surface states directed along [110] are not centered on the surface gallium atoms but centered on the gallium dangling bonds. This places the maximum integrated LDOS of the surface states next to the gallium atoms and between the zigzag rows [56,57] [see Fig. 3(e)]. The odd numbered states will coincide more with the rows of the C4 states and the even numbered states will fall between them, producing the observed alternation in contrast with depth. The regularly increasing extension of the features combined with the arguments for the intensity of the dark features at negative voltage and the positioning of the features on the grid leads to the conclusion that our labeling of “0” to “4” corresponds to the ordering in distance of the nitrogen atom from the cleavage surface.

In order to further investigate the depth dependence of the observed features, tight-binding (TB) calculations, similar to those in Ref. [59], were performed for a single nitrogen atom in an effectively infinite GaAs crystal. Previous calculations of the spatial structure of nitrogen-related states in GaAs have been performed with density functional theory [31,42] with a reduced set of $k$ points and a finite supercell. Here, a $sp^3d^5s^*$ Hamiltonian [60] is used to describe the GaAs crystal and the Koster-Slater method [61] is used to include the effect of the nitrogen. This Green’s function method is computationally efficient and does not suffer from supercell size restrictions or boundary effects. The energy of the nitrogen resonance has been set by including an onsite atomic potential equal to the difference in $s$- and $p$-state energies between nitrogen and arsenic. The bonds between the nitrogen and its nearest neighbors have then effectively been shortened using Harrison’s $d^{-2}$ scaling law [62] to place the nitrogen resonance at 1.68 $\text{ eV}$. This energy is defined as the energy from the valence band edge and is derived by adding 165 meV, the middle of the 150–180 meV range found as the distance with respect to conduction-band edge for the isolated nitrogen level [1], to the 1.52- eV band gap of GaAs at 0 K [63].

Figure 4(b) shows the calculated LDOS in (110) planes at various distances from the center of the nitrogen atom at this resonance energy. The first column is the slice through the plane containing the nitrogen atom, which would correspond with a nitrogen in the top layer of the sample surface measured in STM. The second column then shows the slice displaced one atomic plane from the nitrogen atom corresponding to the contrast measured for the nitrogen in the first layer [label 1 in Fig. 3(b)] and so forth. The calculations show a barlike feature extending along the [110] direction for the nitrogen in the zeroth/top layer and crosslike features extending in the [001] direction for cuts away from the center with an asymmetry between the two lobes. For each layer deeper into the GaAs the enhanced LDOS cross section expands an additional row in the [001] direction.

Comparing the TB calculations to the measured contrast shows an excellent agreement. The series of Fig. 4(a) shows the same systematic increase of one row of bright contrast in the [110] direction as the calculations show in Fig. 4(b) for each cut one monolayer further away from the nitrogen atom. A striking resemblance between calculation and measurement is found in the direction of extension of the nitrogen-related LDOS shape which at the surface (or zeroth plane) extends in the [110] direction, while the features from other planes extend in the [001] direction. The best correspondence between measurements and calculations is obtained with a tip width of 1.70 Å.

As can be seen from Figs. 4(c) and 4(d), the calculated isosurfaces of state density have highly anisotropic shapes. The tip width in the calculation has been chosen smaller, 1.13 Å, to make the finer features of the isosurface clearer. At a high value of the density of states the tetragonal symmetry close to the nitrogen center is recognizable. The isosurface at lower density further away shows somewhat of a preference for the [110] directions, similar to what was reported by Virkkala et al. [31], but far less localized. The panels in Fig. 4(b) show the LDOS in parallel (110) planes that either cut through the N atom, as is the case for the zeroth plane, or at an integer number of atomic planes away from the N atom. In the zeroth plane, the LDOS is mainly related to the two arms of the 12-fold symmetric electron density that lie in the (110) plane cutting through the N atom. In a plane that is a few monolayers away from the N atom the atomic-sized LDOS is mainly due to the arm that is pointing in the [110] direction, i.e., perpendicular to the arm in the zeroth plane. In planes at intermediate distances away from the N atom, the LDOS consists of the perpendicular [110] arm and four others arms of the 12-fold symmetric state that cut at an angle with the (110) plane. Strongly anisotropic shapes for the LDOS along the [001] have been reported for several acceptor impurities with levels in the band gap [64,65] including Mn [66,67]. The anisotropy seen in acceptor states comes from the symmetry of the tetrahedral bonds in the cubic lattice and the contributing orbitals, namely, the $d$ orbitals with $T_2$ symmetry and the $p$
A prerequisite to observe the states related to such a center, on the formation of these localized isoelectronic states. A strong distortion of the lattice, could provide further insights to gallium, as well as antimony and bismuth, which cause a high electronegativity. Studies on isoelectronic substitutional local nature of the nitrogen is attributed to its small size and for through a corresponding reduction at other energies. The not have to be an integer. The nitrogen atoms have the same energy. The integral of this region of enhanced LDOS does resonances within the continuum of the conduction band that produces an integer value. The nitrogen atoms, however, form localized state in the band gap, the spatial integral of the LDOS acceptor states, we note that for acceptor atoms that give rise to a and observations [10,13,17,18,20].

FIG. 4. (a) Measured contrast at +0.75 V for the features in the zeroth/top layer and below. (b) The calculated LDOS for nitrogen atoms in the zeroth/top layer and below, with an assumed STM tip width of 1.70 Å. The panels for calculation and measurement are about 3.6 × 3.6 nm. (c), (d) Show the calculated isodensity surfaces at 1.68 eV for the difference between the LDOS near the dopant and the background. To view sharper features in this theoretical surface, the STM tip width is made smaller, 1.13 Å. (c) Corresponds to an LDOS difference from the background of 0.12 eV Å⁻³. (d) Corresponds to an LDOS difference from the background of 0.012 eV Å⁻³.

orbitals which also have $T_2$ symmetry. Although nitrogen is an isoelectronic impurity, the same applies to the bonding of the nitrogen in which $p$ orbitals are contributing. Therefore, in opposition to Ref. [31], we argue that the observed anisotropy of the nitrogen atom is mainly attributed to the symmetry of the surrounding electronic environment and not the strain introduced into the lattice.

The high anisotropy of the nitrogen-related states will have consequences for the interaction between nitrogen centers. As the LDOS is a measure for the amplitude of the wave function, the interaction in the directions where the LDOS is high will be stronger than in the directions the LDOS is low. For example, the overlap between two nitrogen atoms spaced 0.5 nm away in the [001] direction is predicted to be less than two nitrogen atoms spaced 1.0 nm away in one of the (110) directions. Furthermore, it is shown that the extent of the nitrogen is much larger than its atomic position, due to hybridization with the lattice. Interactions beyond nearest neighbors are therefore expected. The larger extent and high directional dependence of the energy levels formed from two interacting nitrogen levels matches earlier calculations [42] and observations [10,13,17,18,20].

Coming back to the comparison to earlier investigated acceptor states, we note that for acceptor atoms that give rise to a localized state in the band gap, the spatial integral of the LDOS produces an integer value. The nitrogen atoms, however, form resonances within the continuum of the conduction band that locally increase the density of states around the resonance energy. The integral of this region of enhanced LDOS does not have to be an integer. The nitrogen atoms have the same number of valence states as arsenic atoms, so the increase in the LDOS at the resonance energy has to be compensated for through a corresponding reduction at other energies. The local nature of the nitrogen is attributed to its small size and high electronegativity. Studies on isoelectronic substitutional impurities, like boron, which is also electronegative compared to gallium, as well as antimony and bismuth, which cause a strong distortion of the lattice, could provide further insights on the formation of these localized isoelectronic states. A prerequisite to observe the states related to such a center, isoelectronic or not, with X-STM is that the increase in LDOS is localized enough in energy and space to significantly change the tunneling current.

The small deviation between our calculations and measurements is due to the fact that the calculations are done for a bulk system, whereas in the experiment the nitrogen atoms are close to a semiconductor-vacuum interface. The surface will reconstruct, deforming the layers close by and putting strain on them [57]. The slight additional asymmetry along the [001] direction may also be explained by surface strain, as seen for Mn acceptors [68]. Moreover, the deformation of the lattice around the nitrogen is only taken into account by changing the hopping parameters to the direct neighbors, without actually changing the lattice positions of the nearest neighbors or accounting for changed bond lengths to the next-nearest neighbors. The nitrogen will, however, deform the lattice even beyond the first neighbors [31] and close to the surface this will happen in a spatially anisotropic way [52]. These strain arguments are very likely the cause of the observed deviations and they are consistent with the observations that the features assigned to nitrogen further away from the surface are more symmetric and match the calculations better.

The calculated shape of the LDOS does not provide an explanation for the two special bright features, B1 and B2, observed at negative voltages (see Fig. 1). At −2.50 V, the bright contrast of the mixed feature B1 disappears, while the dark contrast remains unaltered (see Supplemental Material S2 [53]). The dark contrast is in accordance to what has been reported before for the topographic contrast of a first layer feature [48,51,52]. The center is positioned around a point falling in between the A4/A5 surface states and shows a dark contrast over multiple surface arsenic atoms. This strongly suggests that the observed contrast at −1.90 V is a mix of the expected topographic contrast and a bright contrast element. Feature B2 is associated with the third layer away from the cleavage surface. The expected topographic contrast for a nitrogen in this position is less strong and falls underneath the strong central bar of the bright pattern. We suggest this as the reason why at −1.90 V no topographic contrast element is recognizable for this feature.
The B features become less pronounced with more negative voltages (see Supplemental Material S3 [53]), whereas the topography should dominate more when tunneling further from the band gap. Therefore, it is likely that the bright component of the contrast stems from an electronic rather than a topographic origin.

Noticeably, the bright contrast element only appears with the nitrogen atoms substituting in the odd numbered positions. Tilley et al. [52] calculated that the nitrogen atoms in those positions displace multiple arsenic atoms in the surface.

Voltage-dependent measurements on the B2 feature (see Supplemental Material S3 [53]) suggest that the visibility of the state is related to the visibility of the C3 surface state. At less negative voltages, the C3 surface state as well as the B2 feature are more pronounced. At a low positive voltage of +0.45 V where the C3 mode dominates, a feature very similar to the one observed at negative voltages can be observed (see Supplemental Material S3.2 [53]). Therefore, we propose the bright contrast of the B features might be related to a disturbance of the C3 surface state. This would be consistent with the larger spread of the B2 feature compared to the B1 feature. The disturbance of the surface due to the deeper lying nitrogen atom would be more extended and that of the shallower nitrogen atom would be more localized. Remarkably, the B2 feature shows a brighter overall contrast than the B1 feature.

IV. CONCLUSIONS

We performed X-STM measurements on individual nitrogen impurities in GaAs layers grown with MBE. The impurities were studied at different voltages. At negative voltages, mainly topographic contrast appeared. At low positive voltages, highly anisotropic bright shapes were observed which show voltage-dependent brightness. The resonant tunnel voltage changes with the layer the nitrogen is situated in due to TIBB, with exception of the surface nitrogen that likely shows an additional increase in energy on account of a highly disrupted symmetry in bonding with respect to the bulk. The anisotropy of the isolated nitrogen state can be identified as a cause for the high directional dependence of the levels stemming from nitrogen pairing. At higher positive voltages, less-defined dark shapes are observed, unlike the topographic contrast observed at negative voltages. This we relate to a decrease of LDOS compensating the increase of LDOS at lower energy. Using the difference in extent of the observed features at low positive voltages and the atomic corrugation coming from the voltage-dependent surface states, the features can be assigned to nitrogen at different planes below the cleavage surface. TB calculations give similar anisotropic enhanced LDOS at (110) cuts through and next to the nitrogen center. The excellent match verifies experimentally that the TB can describe the nitrogen center accurately and can be used as a base for further calculations combining single nitrogen states. These results show that the delocalized anisotropic appearance of the LDOS originates from the symmetry of the GaAs lattice rather than long-ranged strain. Minor deviations between the experimental and theoretical contrast can still be attributed to the deformation of the lattice, caused by surface relaxation and the small nitrogen atom, which is only partially accounted for in these bulk calculations. The hybridization of the nitrogen impurity center with the bulk dispersion makes the extent of the enhanced LDOS carry much further than the atomic position of the nitrogen impurity, making interactions plausible over larger ranges than first neighbors expected from simple atom-to-atom-bonding considerations. At negative voltages not only topographic features are observed, but for two features B1 and B2, a resonant electronic component with an alteration in the [110] direction is found as well. These features can be attributed to nitrogen in the first and third layers away from the cleavage surface. Earlier calculations and measurements show that these are the positions in which the disturbance of the surface is the most delocalized. Measurements at varying negative voltages show that a relation with the C3 resonant state is likely.

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